

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Yukio MORISHIGE, et al.

Group Art Unit: 1763 Appln. No.: 09/989,162

GROUP 1700 Examiner: Sylvia R. MACARTHUR Confirmation No.: 9610

Attorney Docket No.: Q67394 Filed: November 21, 2001

THIN FILM FORMING EQUIPMENT AND METHOD For:

AMENDMENT UNDER 37 C.F.R. § 1.111

MAIL STOP NON-FEE AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Office Action mailed April 4, 2003, please amend the above-identified application as follows:

IN THE CLAIMS:

Please cancel claims 10 and 12 without prejudice or disclaimer.

Please enter the following amended claims:

9. A method for forming a thin film on a substrate by decomposing gas introduced to a surface of a substrate held by a substrate holding device having a cover body which is disposed in an area surrounding said substrate held by said substrate holding device, said cover body being able to open and close by rotational movement, said method comprising:

a step of preventing said gas introduced to said surface of said substrate from being influenced by outside air,